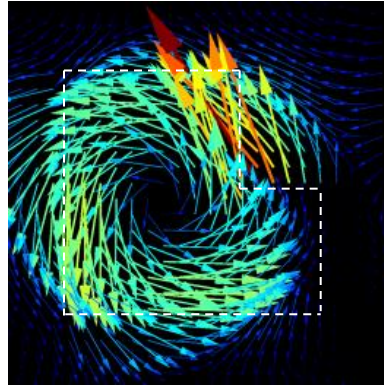


High Quality Factor Fano Metasurfaces



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Fano resonances of dielectric resonator metasurfaces

Fano resonances of metasurfaces:

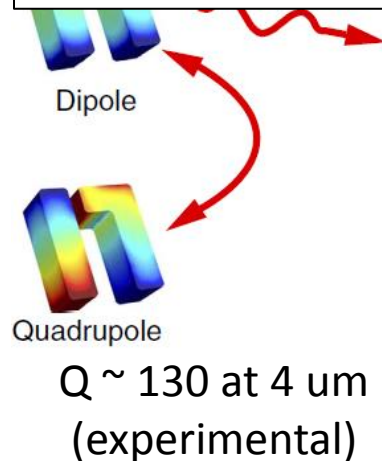
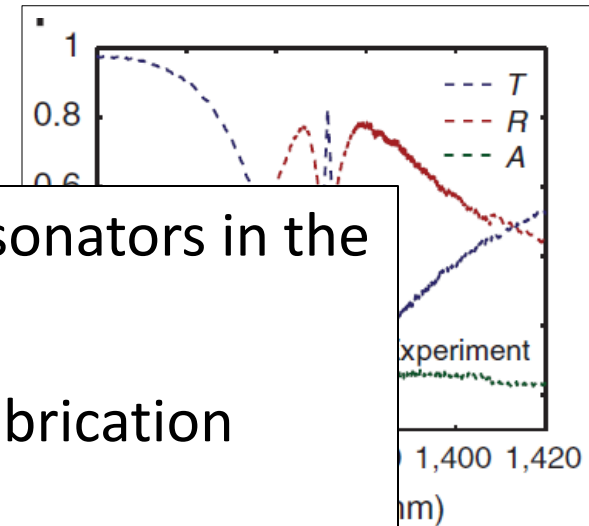
- First proposed for metal metasurfaces

Now

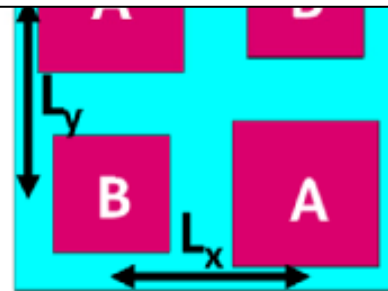
DR Fano designs to-date rely on multiple resonators in the unit cell

Near field coupling extremely sensitive to fabrication errors

Can we find a one-resonator design??

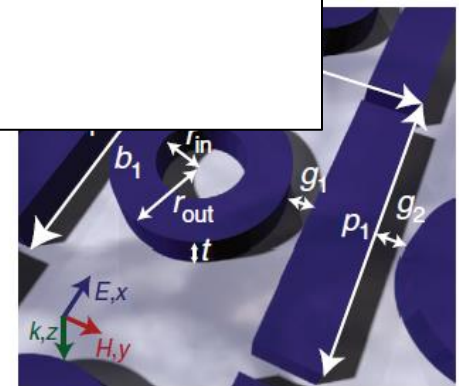


Wu, et al.
Nature Comm. 5, 3892, 2014



$Q \sim 110$ at $1.1 \mu\text{m}$
(simulation)

Wang, et al.
OMEX 5, 668, 2015



$Q \sim 500$ at $1.37 \mu\text{m}$
(experimental)

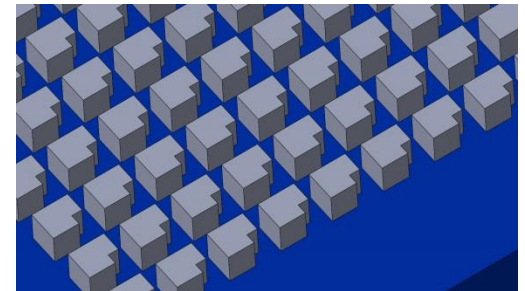
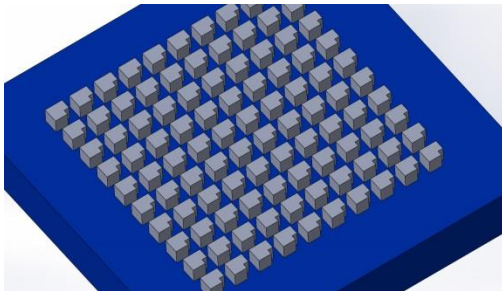
Yang, et al.
Nature Comm. 5, 5753, 2014

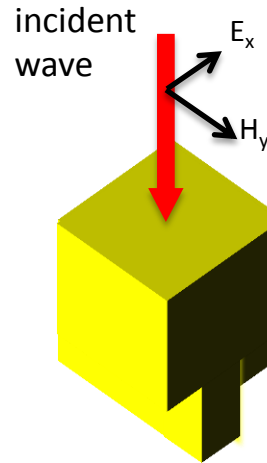


A new, monolithic, Fano resonator metasurface design

Outline

- Operating principles
- Hi-Q monolithic design
- Nature of the Fano mode
- Experimental demonstrations:
 - SOI: measured Q-factor of ≈ 350 at 990 nm
 - GaAs: Q-factor of ≈ 600 at 975 nm

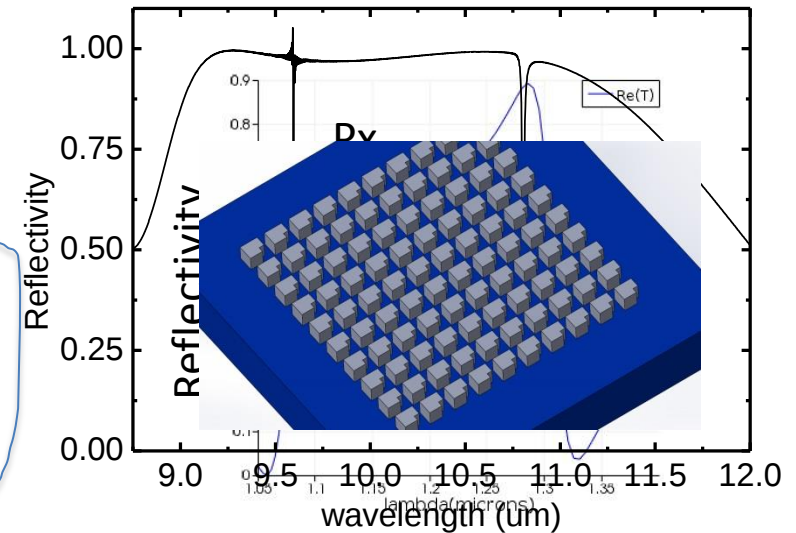
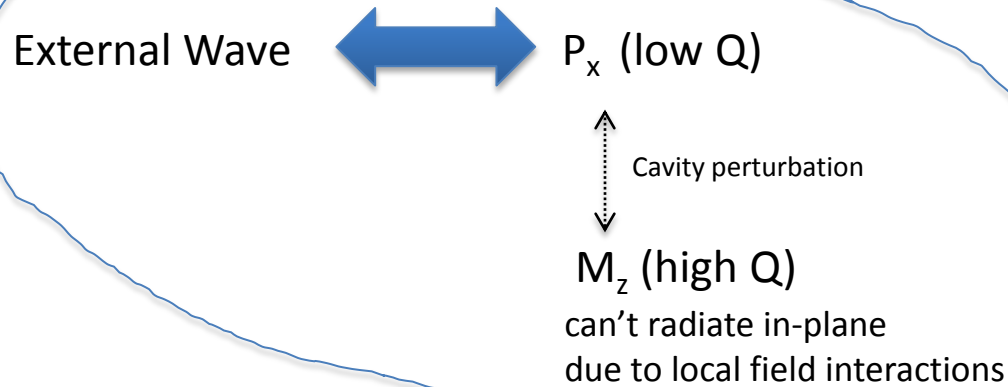




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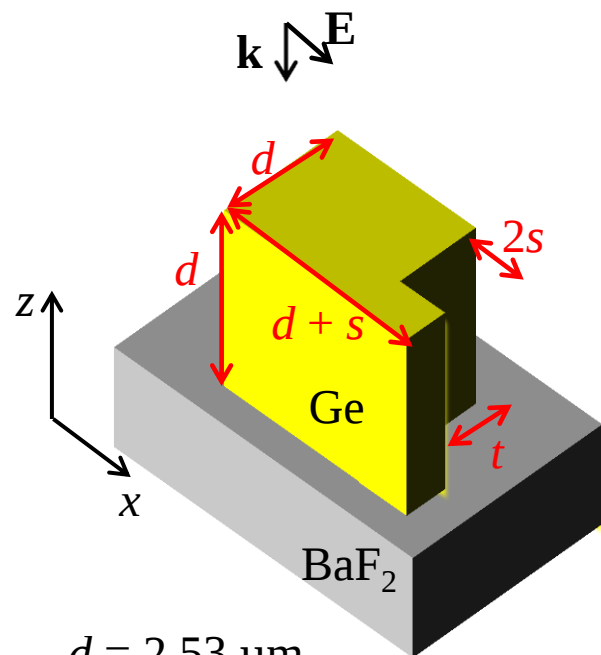


Fano system





Ge-based Fano metasurface design



$$d = 2.53 \mu\text{m}$$

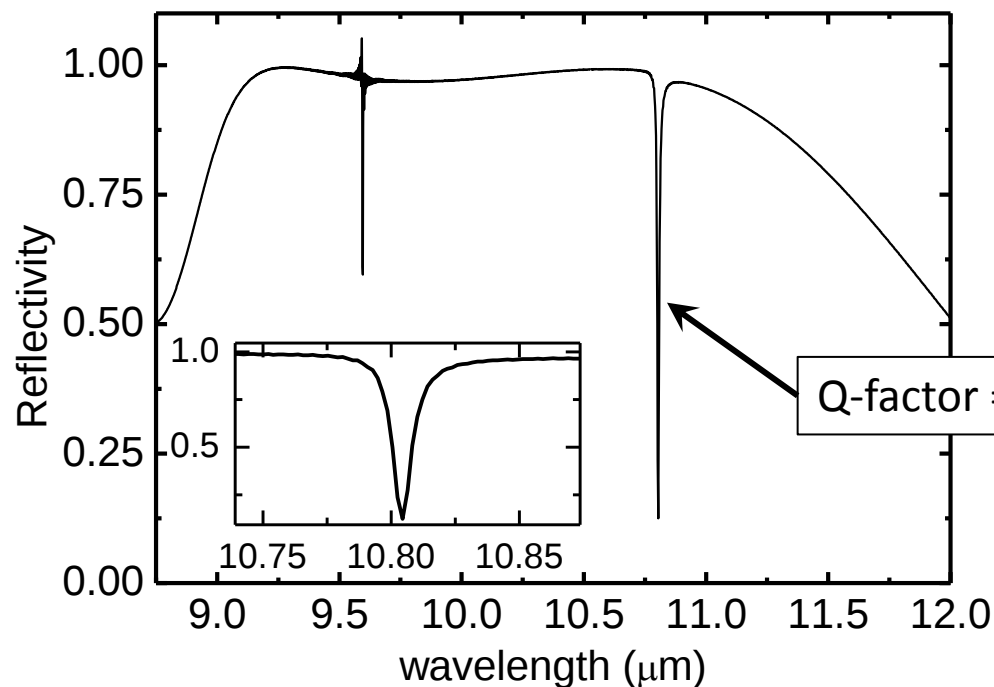
$$s = d / 5$$

$$t = 1.5 \mu\text{m}$$

Array Pitch:

$$a = b = 4.2 \mu\text{m}$$

FDTD Simulation



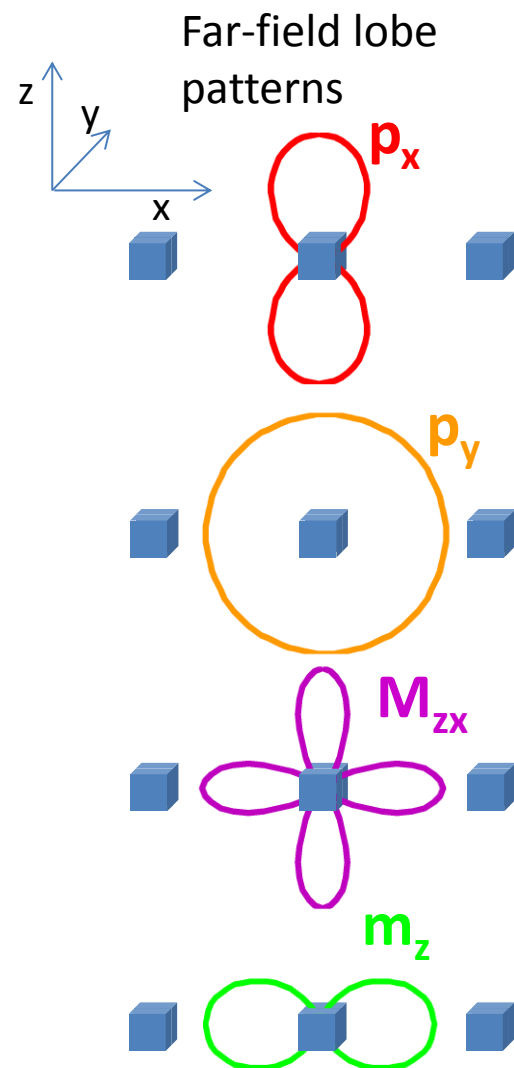
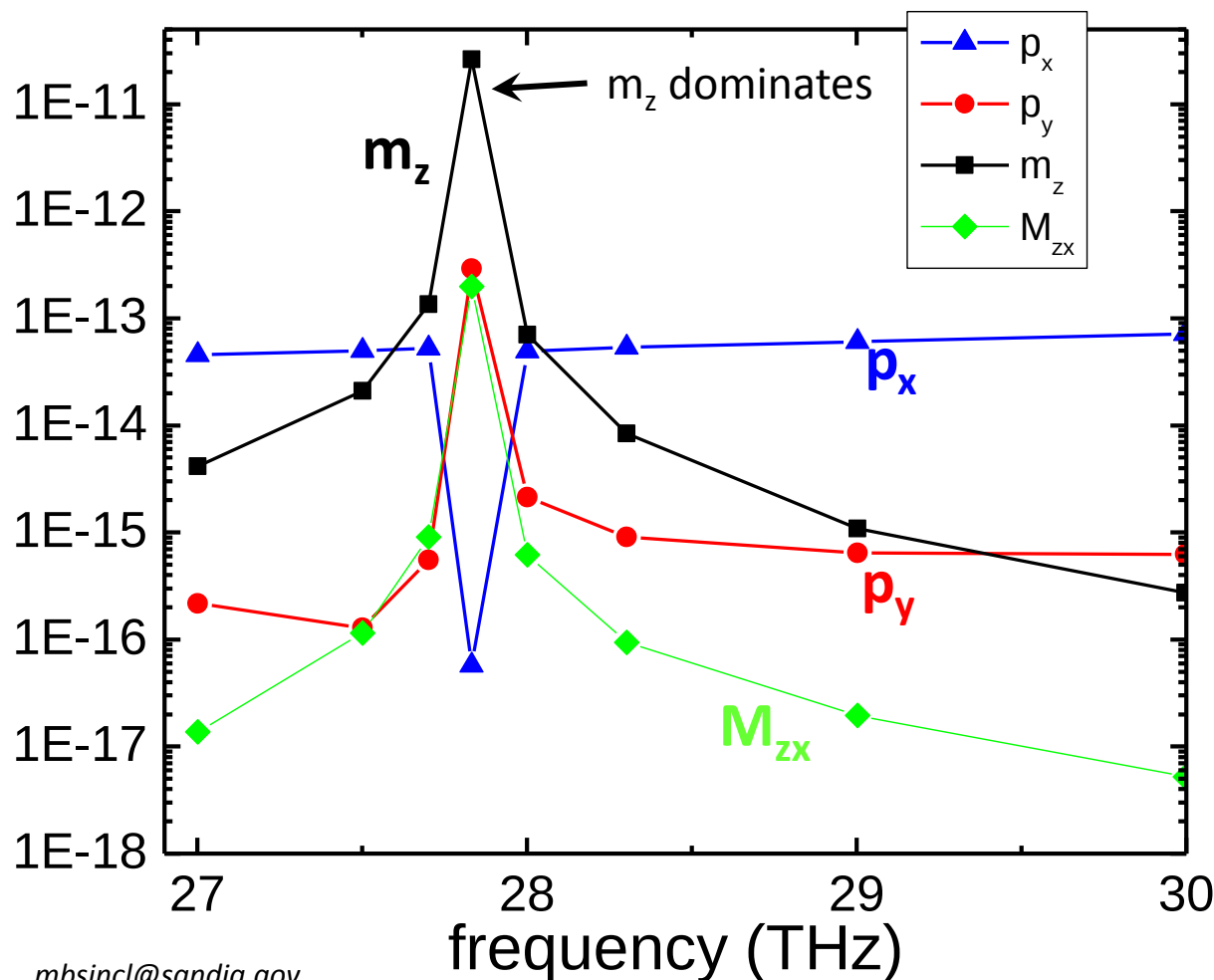
Design is scalable from NIR through RF!



Dr. Salvatore Campione

Multipole decomposition of resonator response

- x-polarized electric field excitation for full array
- Far-field scattering for single cube
- Extract multipole powers

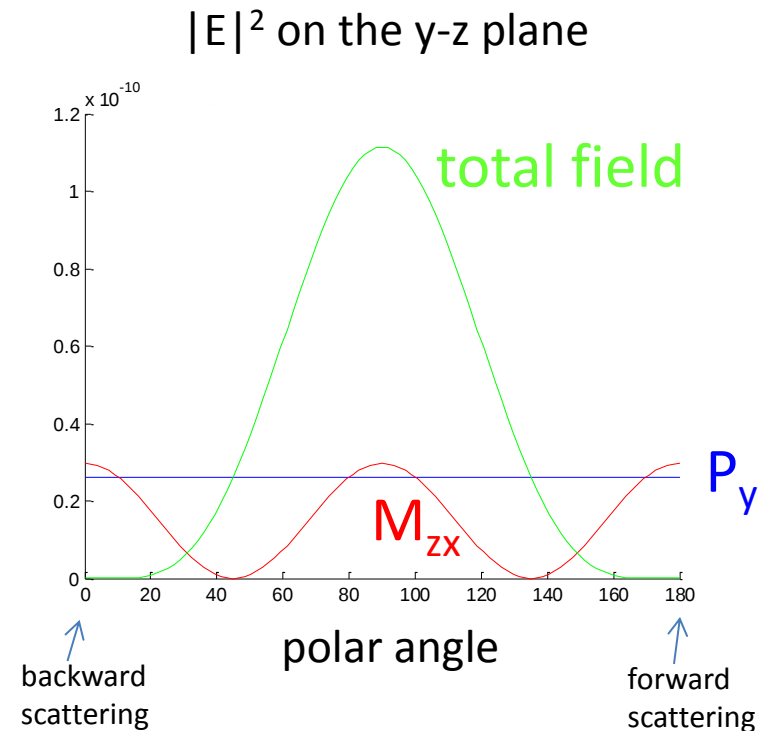
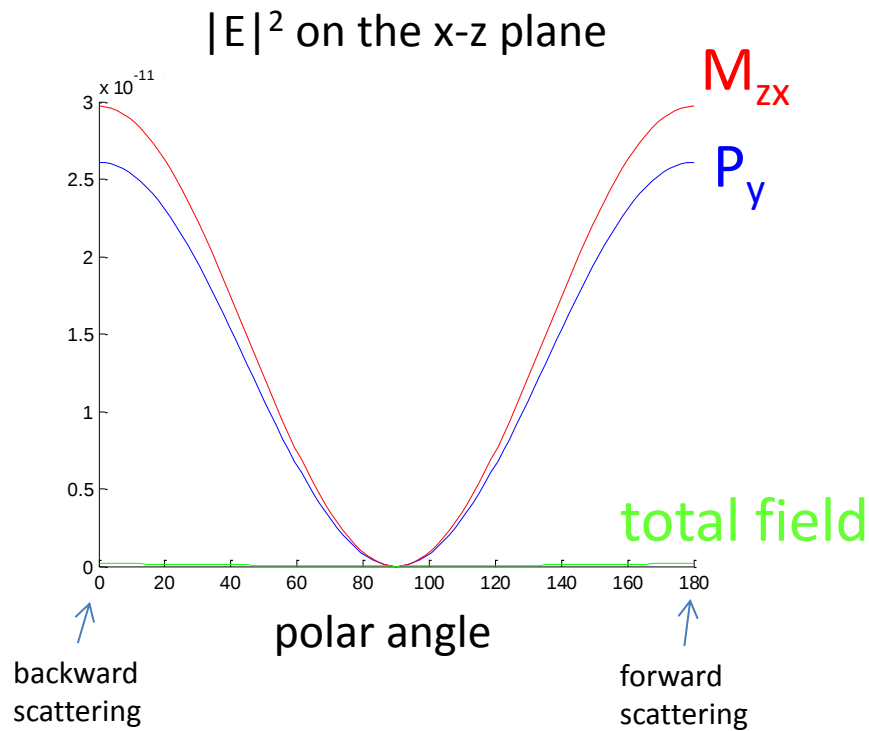




What about P_y and M_{zx} ?

At Fano resonance:

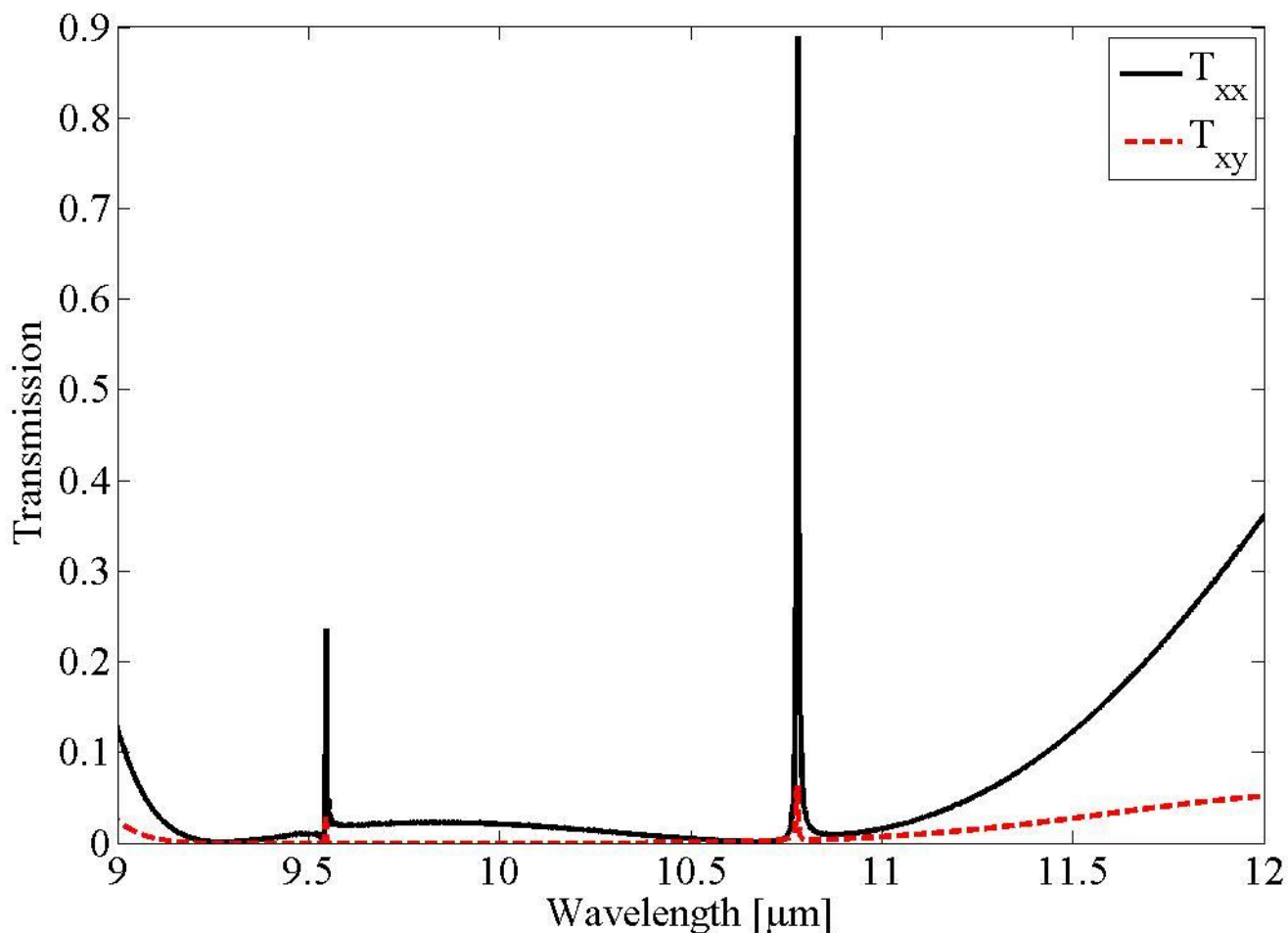
- both multipoles are excited
- radiated fields cancel in forward and backward directions!!





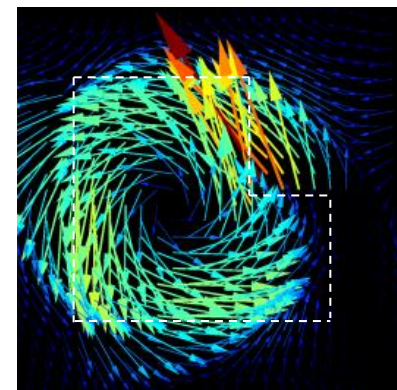
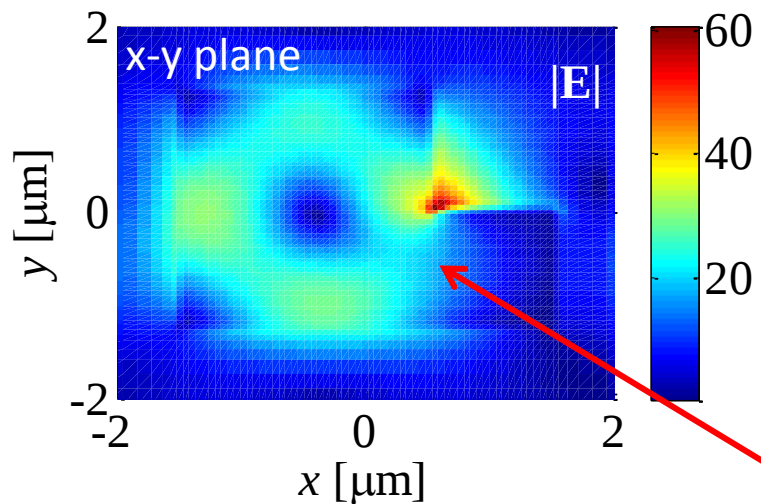
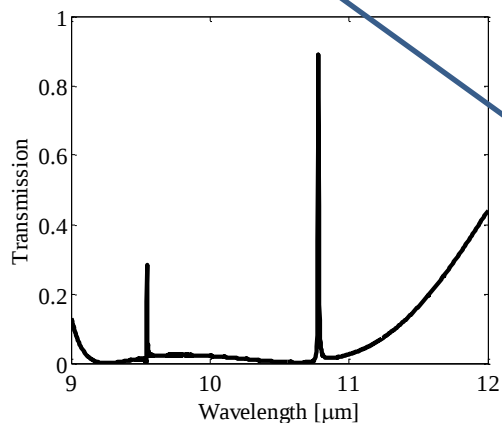
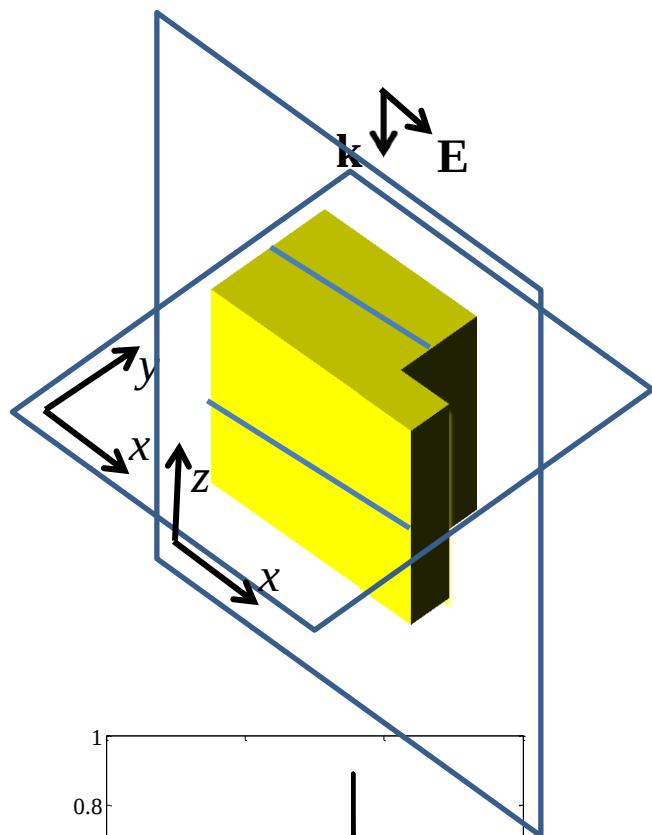
Small cross polarization of transmitted wave

Residual scattering by P_y and M_{zx}

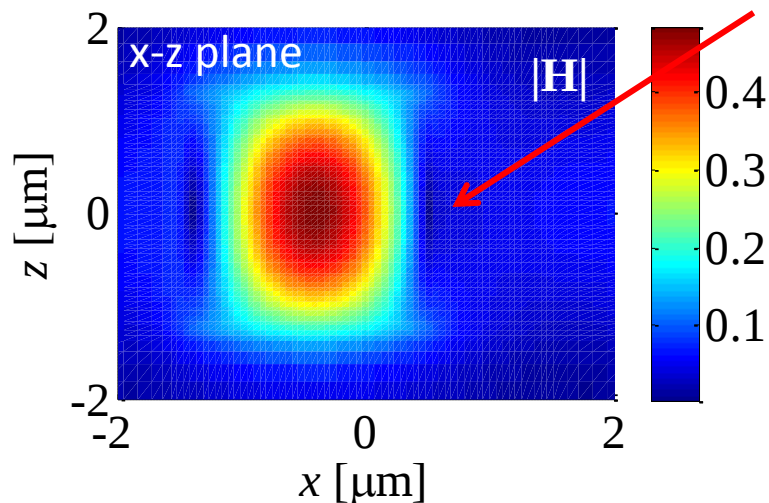


Resonant Mode Field Profiles

FDTD simulations at the $\lambda = 10.8 \mu\text{m}$ resonance



z-directed magnetic dipole



max

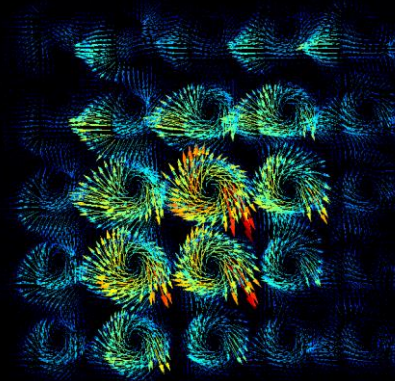
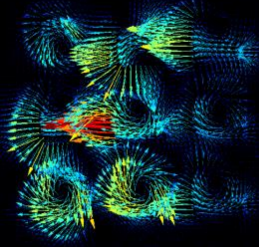
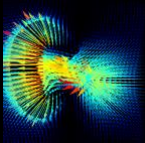
min



Isolated resonator

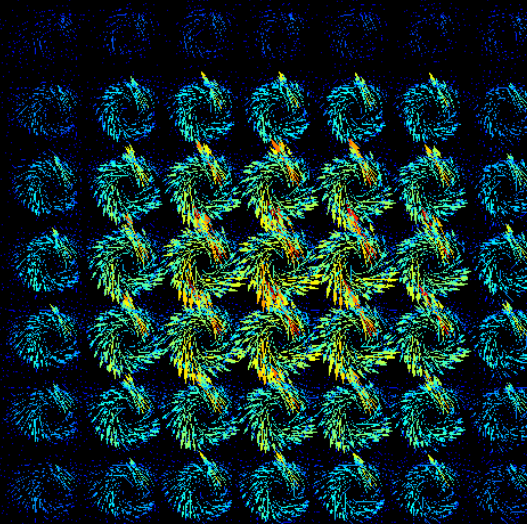
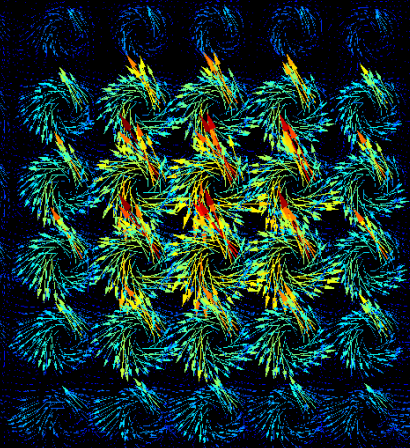
3x3 array

5x5 array



7x7 array

9x9 array

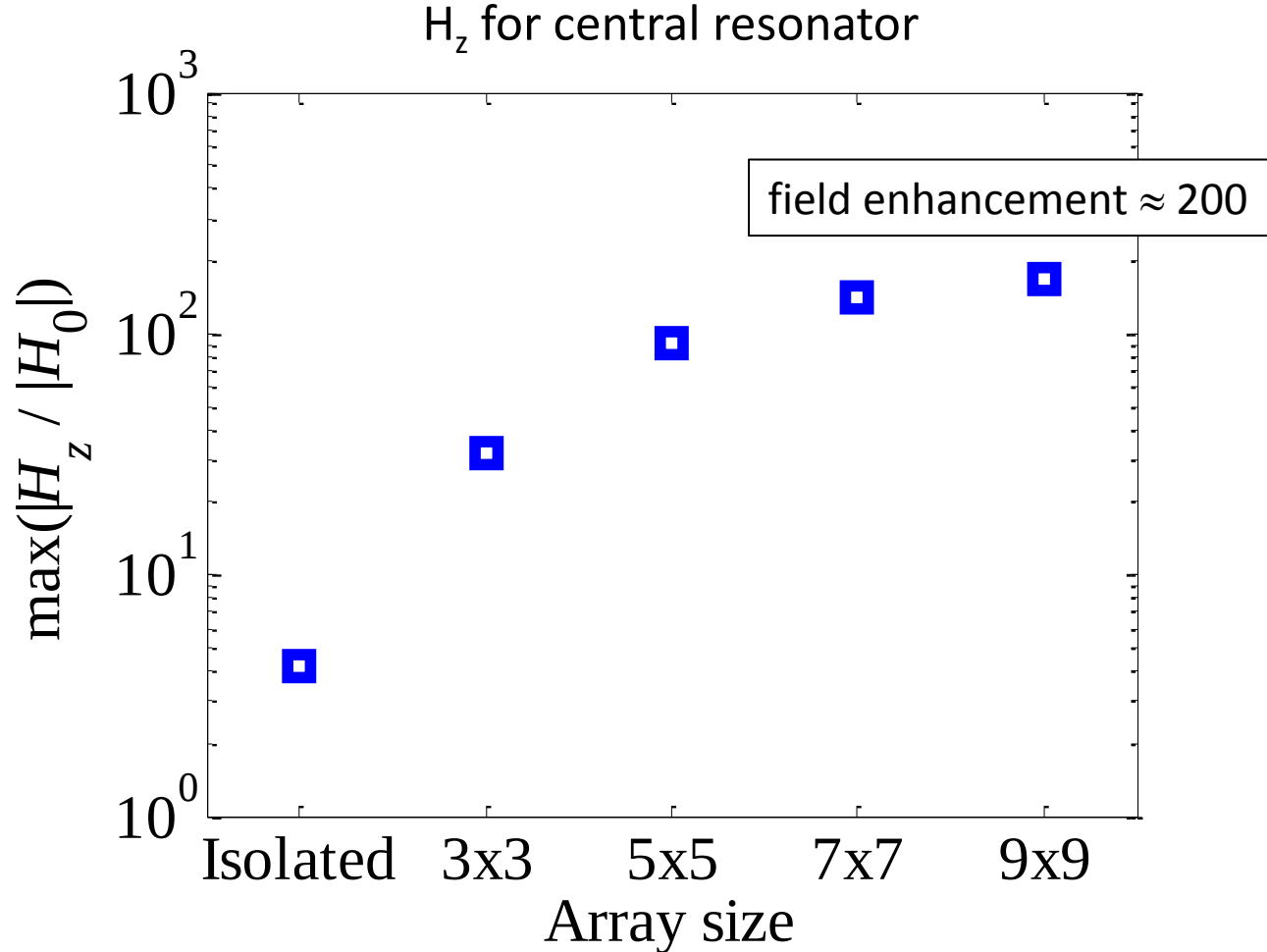


- m_z can't radiate broadside
- local fields inhibit radiation
- weaker resonance at edges of array
- quality factor increases with array size

electric field vector plots



Field Enhancement vs. Array Size



- beginning to saturate for 9x9 array
- effect arises from nearby resonators

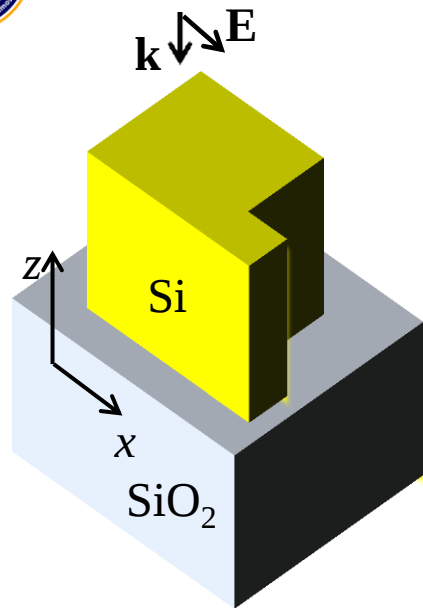


Experimental Demonstrations of Fano Metasurfaces

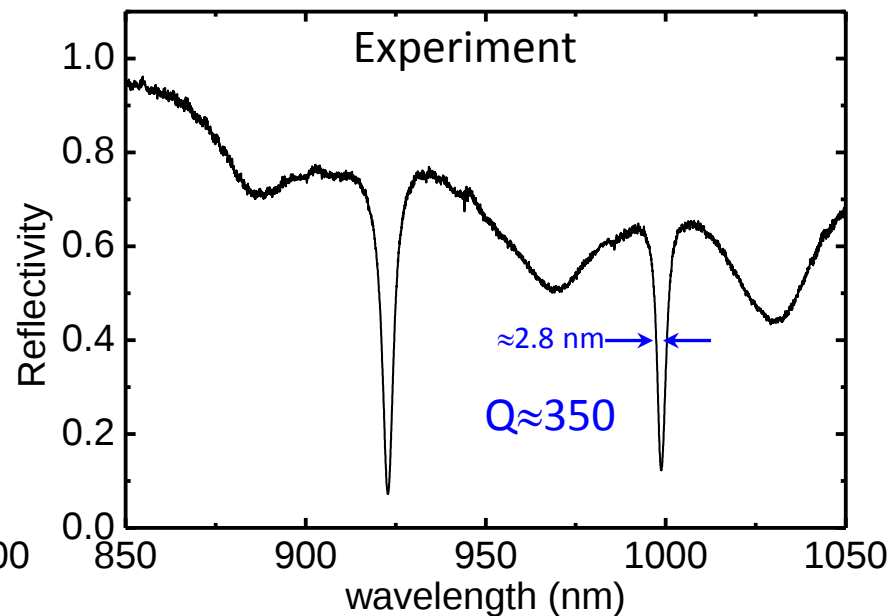
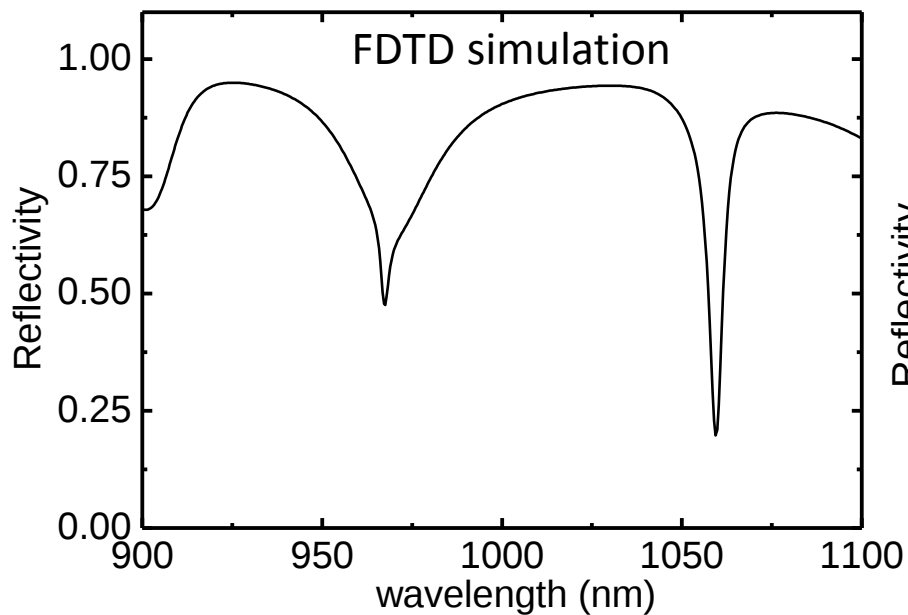
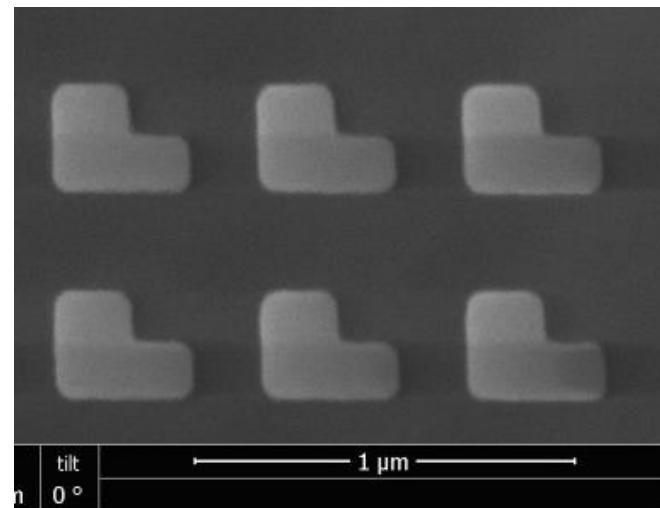
1. Silicon-on-insulator Fano arrays
2. GaAs Fano arrays



Experimental verification: SOI Fano Resonators



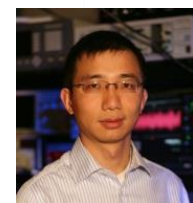
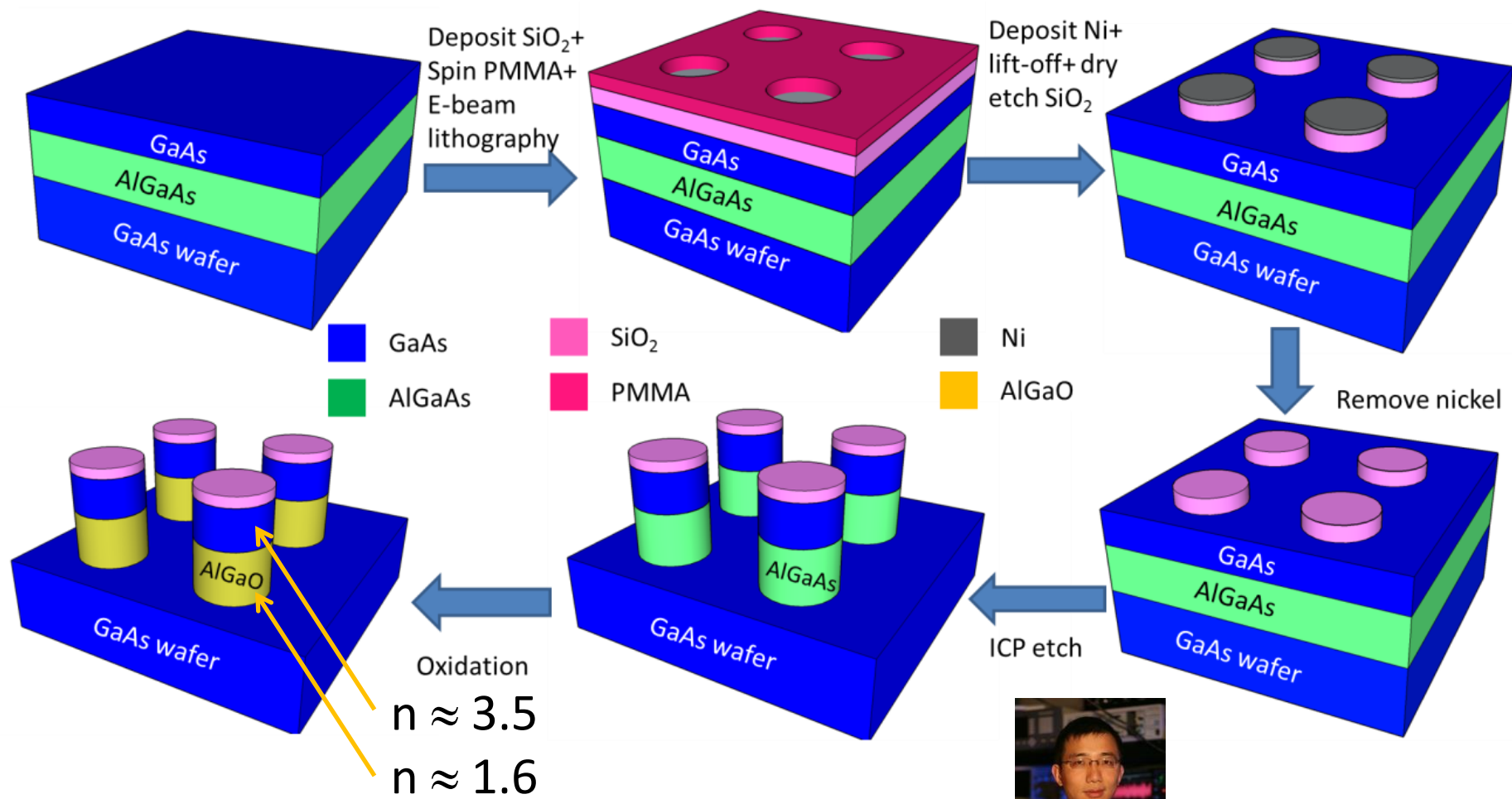
Thickness = 250 nm
Side length $\approx$ 280 nm
Array pitch = 550 nm





DRs are now possible in III-V semiconductors

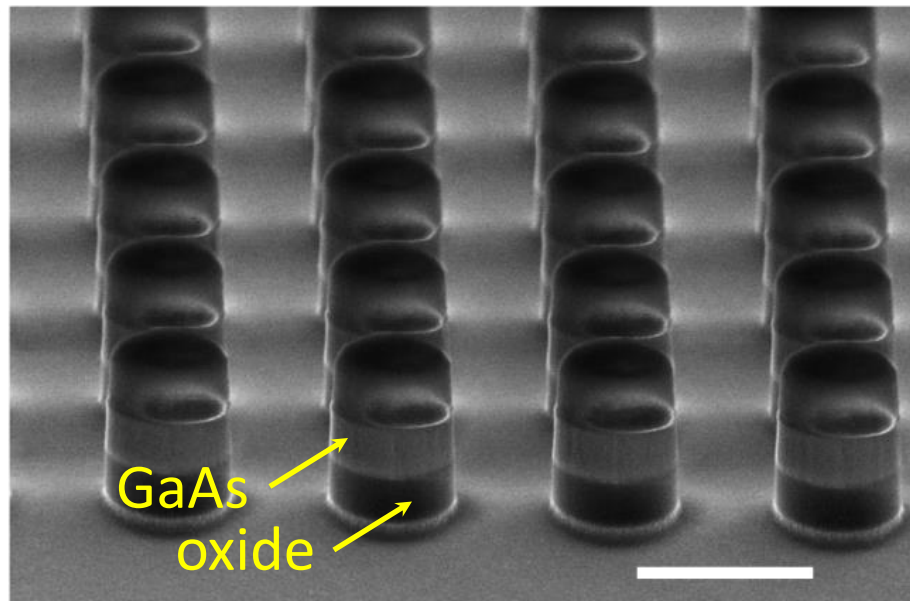
New process for (Al)GaAs resonators



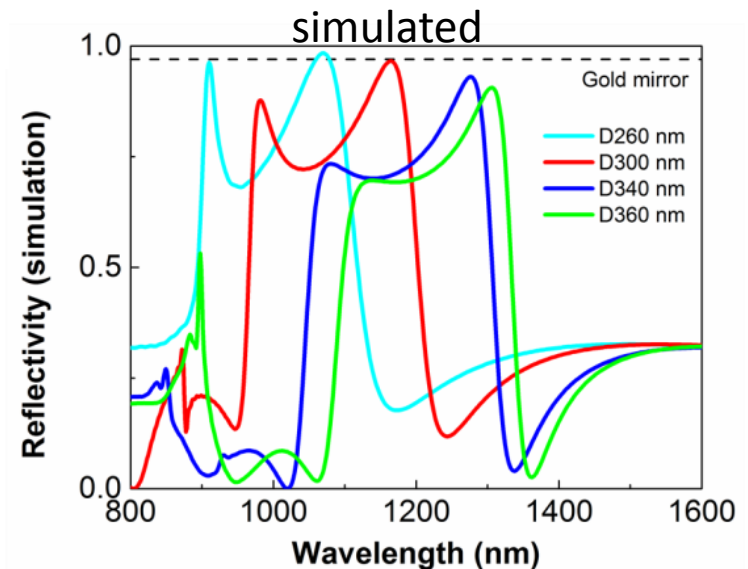
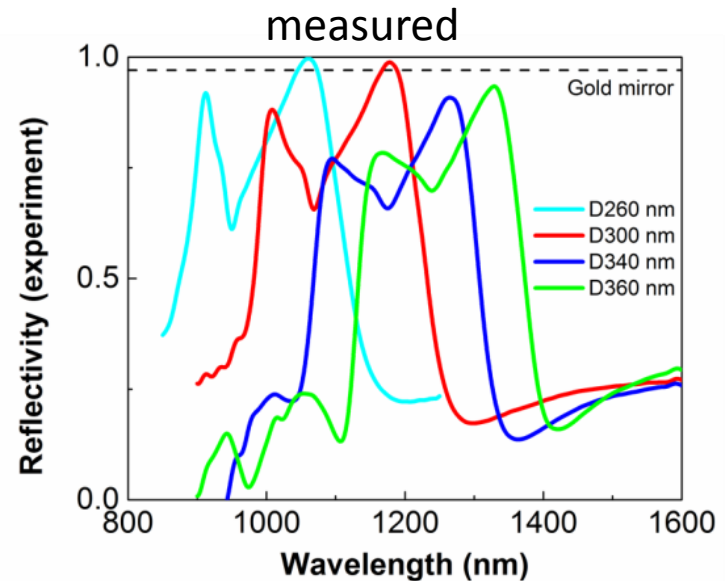
Sheng Liu

GaAs Cylindrical Resonators

- height = 300 nm
- diameter varies near 300 nm

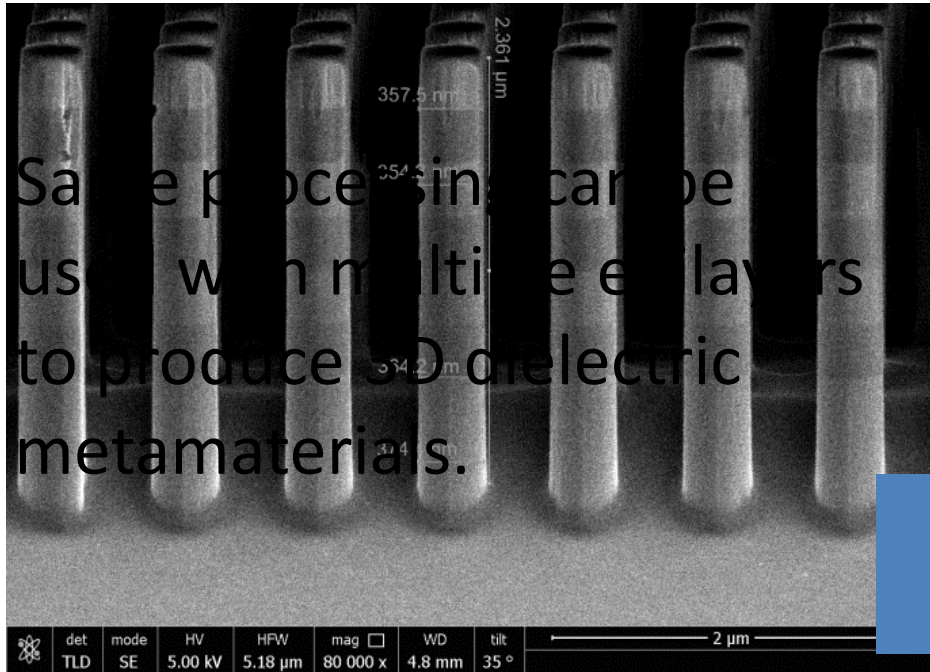


reflectivity exceeds gold at several wavelengths

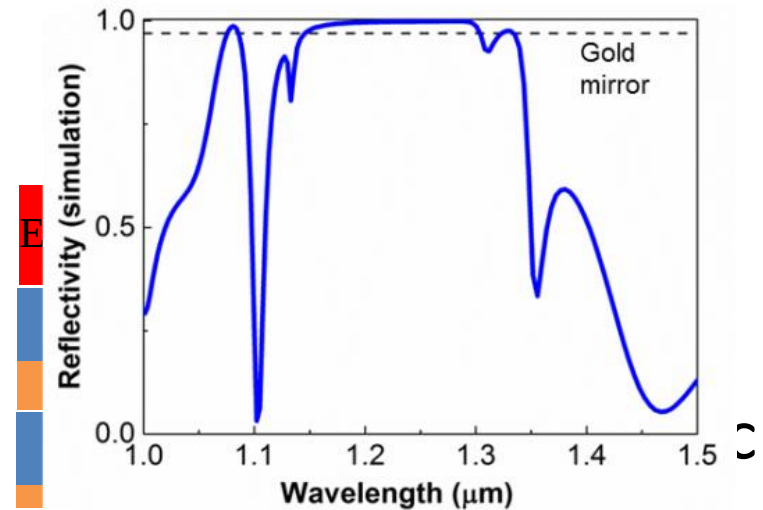




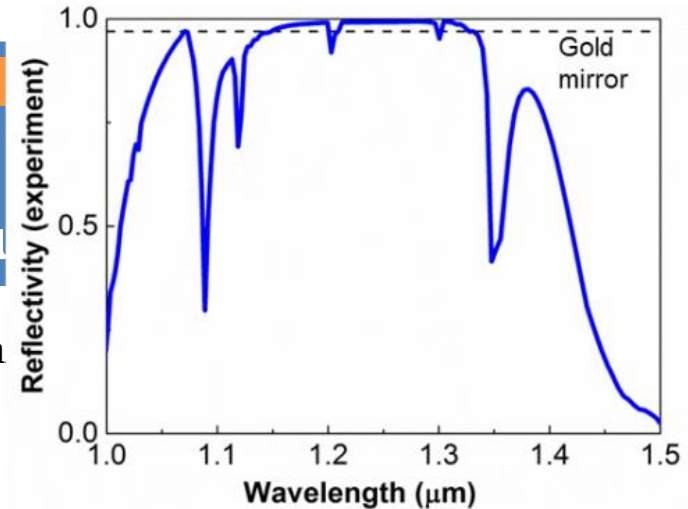
Multilayer III-V Dielectric Metamaterials



Same processing can be used with multiple layers to produce 3D dielectric metamaterials.



metasurface



Broad spectral bands of near perfect reflectivity!

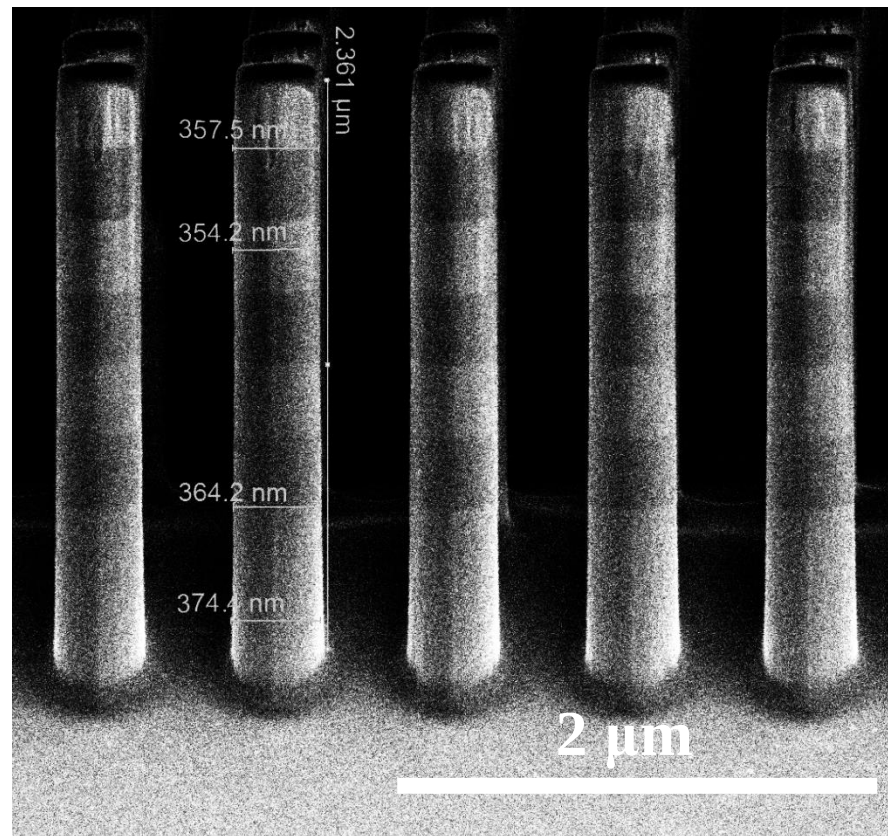
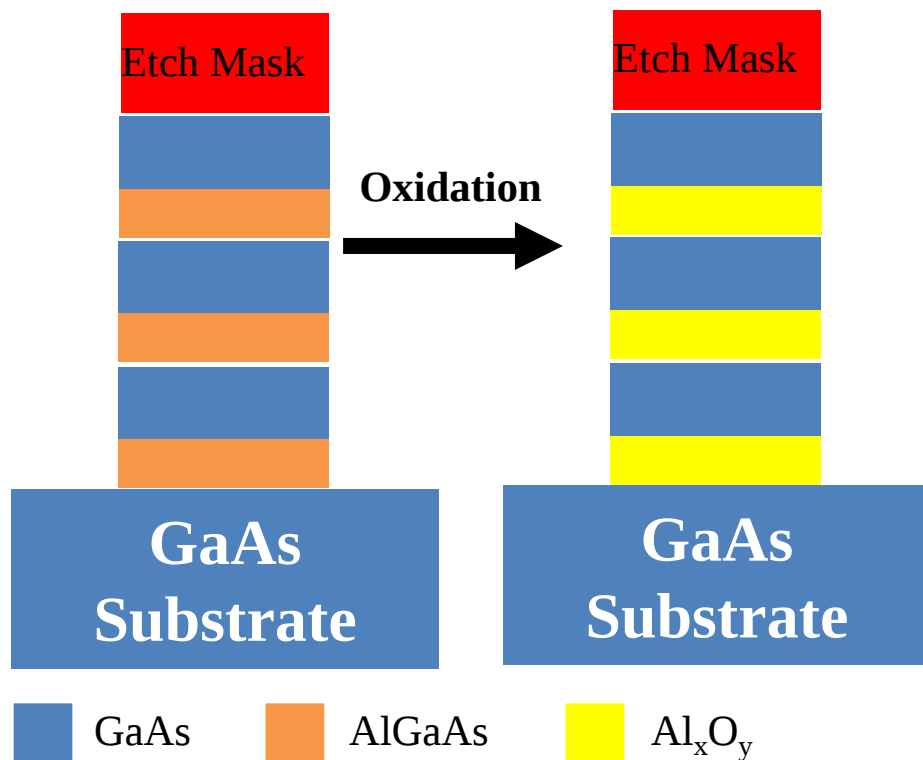


Multilayer III-V Dielectric Metamaterials

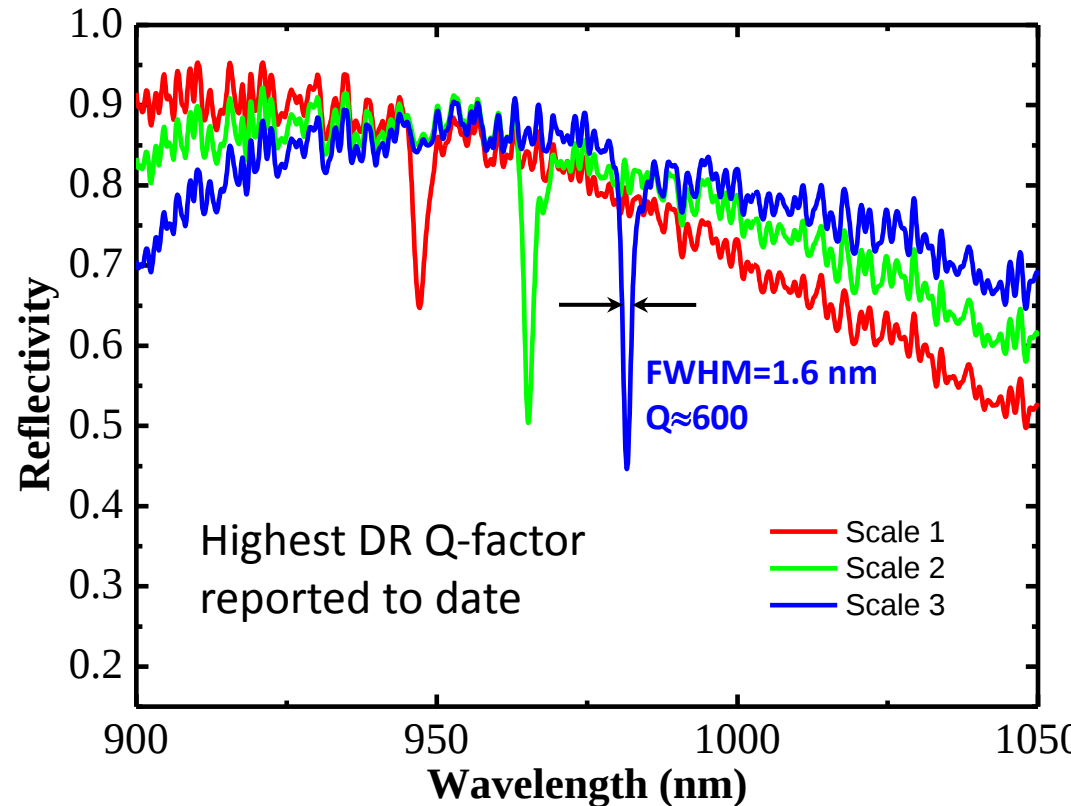
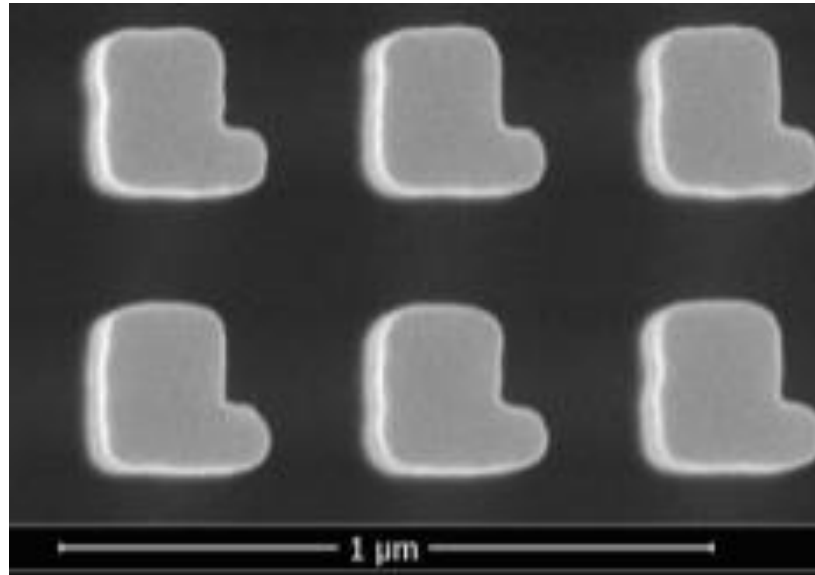


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Epitaxially grown multi-layer
GaAs/AlGaAs



SEM of GaAs Fano resonators



- GaAs is direct bandgap $\rightarrow$ lower absorption losses
- GaAs has a large $\chi^{(2)}$ $\rightarrow$ nonlinear devices (SHG, down-conversion, etc.)
- Can incorporate InGaAs quantum wells for gain and photon detection



Conclusions

- A new, simpler design for dielectric Fano resonator metasurfaces
 - One resonator per unit cell
- Intra-resonator coupling between bright and dark modes
 - Bright electric dipole and dark magnetic dipole
- Approach is scalable from NIR → RF
- High Q-factors for SOI (≈ 350) and GaAs (≈ 600)
- Extension to (Al)GaAs will allow for active devices
 - Spectrally selective detectors
 - Optical modulators
 - Nonlinear devices
 - Lasers??



Acknowledgments



- **Salvatore Campione**
- **Sheng Liu**
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- **Gordon Keeler**
- **John Reno**
- **Igal Brener**



END